Application No.: 10/742,919 Docket No.: 8733.966.00-US

REMARKS

At the outset, the Examiner is thanked for the thorough review and consideration of the pending application. The Office Action dated October 5, 2005 has been received and its contents carefully reviewed.

Claims 1 and 9 are hereby amended. Claims 5-8 and 14-16 are withdrawn. Accordingly, claims 1-16 are currently pending. Reexamination and reconsideration of the pending claims is respectfully requested.

In the Office Action, claim 11 is rejected under 35 U.S.C. §112, second paragraph.

Applicant amends claim 9 to overcome this rejection. Claims 1-4 and 9-13 are rejected under 35 U.S.C. § 102(e) as being anticipated by U.S. Patent Publication No. 2003-0081155 to Moon.

The rejection of claims 1-4 and 9-13 is respectfully traversed and reconsideration is requested. Claims 1-4 are allowable over the cited references in that each of these claims recites a combination of elements including, for example, "a UV-hardening sealant at a circumference of the black matrix layer between the first and second substrates...[and] a metal pattern between the UV-hardening sealant and the first substrate... wherein the metal pattern completely overlaps the UV-hardening sealant." Moon does not disclose teach or suggest at least this feature of the claimed invention. The structure of claim 1 of the present invention is different from the Moon structure in that Moon does not disclose or suggest "a metal pattern between the UV-hardening sealant and the first substrate". Accordingly, Applicant respectfully submits that claim 1 and claims 2-4, which depend from claim 1, are allowable over the cited references.

Claims 9-13 are allowable over the cited references in that each of these claims recites a combination of elements including, for example, "forming a metal pattern in a dummy region of [[a]]the first substrate having active and dummy regions; forming a black matrix layer in a dummy region of a second substrate having active and dummy regions; [and] depositing a UV-hardening sealant at a circumference of the black matrix layer on the second substrate...wherein the metal pattern completely overlaps the UV-hardening sealant". Moon does not disclose teach or suggest at least these features of the claimed invention. The structure of claim 9 of the present invention is different from the Moon structure in that Moon does not disclose or suggest

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"wherein the metal pattern completely overlaps the UV-hardening sealant". Moon discloses in Figs. 6D, 11D, and 12C that the metal pattern 340 partially overlaps the UV-hardening sealant 310. Accordingly, Applicant respectfully submits that claim 9 and claims 10-13, which depend from claim 9, are allowable over the cited references.

Applicants believe the foregoing amendments place the application in condition for allowance and early, favorable action is respectfully solicited.

If for any reason the Examiner finds the application other than in condition for allowance, the Examiner is requested to call the undersigned attorney at (202) 496-7500 to discuss the steps necessary for placing the application in condition for allowance. All correspondence should continue to be sent to the below-listed address.

If these papers are not considered timely filed by the Patent and Trademark Office, then a petition is hereby made under 37 C.F.R. §1.136, and any additional fees required under 37 C.F.R. §1.136 for any necessary extension of time, or any other fees required to complete the filing of this response, may be charged to Deposit Account No. 50-0911. Please credit any overpayment to deposit Account No. 50-0911. A duplicate copy of this sheet is enclosed.

Dated: January 4, 2006

Respectfully submitted,

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